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(37 CFR §1.98(b)) August 10, 2001	Art Unit	
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U.S. Patent Documents							
Examiner Initial	Desig. ID	Patent Number	Issue Date	Patentee	Class	Subclass	Filing Date If Appropriate
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Foreign Patent Documents or Published Foreign Patent Applications								
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	AL							
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(	Other Documents (include Author, Title, Date, and Place of Publication)						
Examiner Initial	Desig. ID	Document					
UB	AQ	C.W. Kim et al.; "42.1: A Novel Four-Mask-Count Process Architecture for TFT-LCDs"; SID 00 Digest; pp. 1006-1009; 2000					
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Substitute Form PTO-1449 (Modified)	U.S. Department of Commerce Patent and Trademark Office	Attorney's Docket No. 12732-068001	Application No. 09/925,512
	losure Statement	Applicant Hideto Ohnuma et al.	
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( NOV 0 8 2001 )			U.S. Paten	t Documents			
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1164	AL	EP 1 003 223	05/24/2000	Europe	H01L	29/786	N/A		
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